Wood Plastic Composite Using Different Monomers in Presence of Additives

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SYNOPSIS

Wood plastic composites (WPC) are prepared with low density wood simul under Co-60 gamma radiation using acrylamide (AM), butyl methacrylate (BMA), and styrene (ST) as the bulk monomers at different compositions with methanol used as swelling agent. The effect of additives, e.g., polyfunctional monomers and oligomers, used by 1% v/v or w/v, on the polymer loading and tensile strength of the composites is investigated. Polyfunctional monomers are N-vinyl pyrrolidone (NVP), tripropylene gylcol diacrylate (TPGDA), and trimethylol propane triacrylate (TMPTA). Oligomer additives are urethane acrylate (UA), epoxy acrylate (EA), and polyester acrylate (PEA). Increased polymer loading (PL) with enhanced tensile strength (TS) are obtained with the composite. Incorporation of a small amount (1% v/v or w/v) of coadditives like sulfuric acid (H⁺), lithium nitrate (Li⁺), copper sulfate (Cu^{2+}) , and urea (U) into the impregnating solutions containing the additives has significantly influenced the PL and TS values of the WPC. Though the H^+ ion has synergistically enhanced the PL, but it has drastically reduced the TS values. Li⁺ ion has played a good role for the replacement of H^+ ion. Urea has substantially increased the PL values with relatively small enhancement of TS. Cu²⁺ ions have retained both PL and TS values of the WPC, which could be used as protective and preservative purposes of the composites. © 1993 John Wiley & Sons, Inc.

INTRODUCTION

In the wood plastic composite (WPC) preparation, the role of impregnating monomers is very important. Some of the monomers are easily augmentable with the substrate during the composite formation under the impact of heat or irradiation. This depends on the structures and functional groups of the monomers. However, the cellular arrangement of the wood substrates shares similar importance for the composite preparation. Recently, some works were done to prepare the wood plastic composites using simul, a Bangladeshi soft wood in combination with different monomers.¹ The impact of organic and inorganic additives present with the bulk monomers is also studied on the tensile properties of the composites.^{2,3} In the present investigation, a set of three bulk monomers such as styrene (ST), acrylamide (AM), and butyl methacrylate (BMA) was used to study their roles in the preparation of the composites in the presence of a number of additives from polyfunctional monomers and oligomers, and organic and inorganic coadditives, both used by 1% v/v or w/v.

EXPERIMENTAL

Substrate

Simul (Salmalia malabarica) wood samples (6.2 $\times 0.8 \times 0.4$ cm) were uniformly polished before removing free water from within the substrate by baking them at 70°C under 50 mm Hg pressure.

Monomer

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Styrene (ST), acrylamide (AM), and butyl methacrylate (BMA) were procured from E. Merck and used as received.

Additives

N-vinyl pyrrolidone (NVP), tripropylene gylcol diacrylate (TPGDA), trimethylol propane triacrylate (TMPTA), urethane acrylate (UA), epoxy acrylate (EA), and polyester acrylate (PEA) were obtained from Ajax, Australia.

Coadditives

Sulfuric acid (H_2SO_4) , copper sulfate $(CuSO_4)$, lithium nitrate $(LiNO_3)$, and urea (U) were procured from BDH, U.K.

Swelling Agent

Methanol (BDH) was used as the swelling solvent.

Method

Impregnating solutions were prepared with a monomer/methanol mixture which was combined with an additive and or coadditive. Wood samples soaked for 15 h in the above solution under vacuum (50 mm Hg) were packed in polyethene bags and were irradiated for 3 Mrad at 8 krad/h. These were then heated at 60°C under 50 mm Hg for removing the monomers, ascertained by the constant weight gain. Polymer loading (PL) was determined by the extent of weight gain by the samples. Tensile strength (TS) was measured with an Instron Model 1011 (U.K.). Change of tensile strength T_f was obtained from the relation $T_f = TS_{wpc}/TS_{wood}$, where TS_{wpc} is for the composite and TS_{wood} is for the wood.

RESULTS AND DISCUSSION

Vinyl monomers are normally used for preparing wood plastic composites by radiation technique, because these monomers can easily generate free radicals required for crosslinking purposes during the polymerization process. Three distinct vinyl monomers are used as the bulk monomers in this investigation. One of them is styrene (ST), containing an aromatic ring attached to the vinyl moiety, and is the cheapest among them, while others are acrylamide (AM) having carboamide group to the vinyl chain and the third monomer is the butyl methacrylate (BMA), which has a relatively long chain aliphatic acid group beside the vinyl backbone. All these monomers are soluble in conventional organic solvents, but only acrylamide is soluble in water at all proportions. When the composites are prepared

with simul wood using these monomers (AM, BMA, and ST) as the bulk monomer at different compositions (10-100%) with methanol as swelling agent, it is observed (Table I) that AM produces the highest polymer loading (PL) among these monomers followed by BMA and ST. In addition, this highest PL is obtained at 70% monomer (AM) concentration compared to 90% with BMA and ST and is more than twofold higher than that obtained with ST. It is believed that an equilibrium concentration of the impregnating solution is attained in the copolymerizing region of the backbone polymer (cellulose) of the substrate. The condition of the region may continually change depending on various factors prevailing during the time of the copolymerization. The partitioning/diffusion⁴ of the monomer and/or components of the impregnating solution is one of the factors in such a copolymerization process. Thus, the structural shape, ionic mobility, and possible affinity for interactions among the components of the impregnating solution are some of the factors to be considered. AM has possibly the most favorable partitioning/diffusion ability among the three monomers due to its structural advantages over BMA and ST; thus, AM may yield the highest PL with the highest tensile strength (TS), about 1.5 times higher than the TS values of the composites obtained with BMA or ST.

Effect of Additives

Two series of organic additives are used in order to study their impact on the copolymerization process between the wood substrate and the monomers as well as on the mechanical strength of the composites prepared in the presence of these additives. One set is chosen from a monomer like NVP, a monofunctional monomer (MFA), TPGDA, a difunctionalmonomer (DFM), and TMPTA, a trifunctional monomer (TFM). The second set is selected from oligomer, e.g., UA, containing urethane functional group, EA, having epoxy functional group, and PEA, which has a long chain backbone. These additives are used in a minute quantity 1% (v/v or w/v) with bulk monomer. It is observed (Table I) that TMPTA has produced the highest PL in all the three systems (AM, BMA, and ST) at 50% monomer composition. It is also noticed that the BMA + TMPTA system is more favorable to yield the highest PL compared to ST + TMPTA and AM + TMPTA systems. Additive NVP has the lowest influence for the copolymerization⁵ process between the substrate (simul) and the bulk monomer. However, NVP has

						Mon	omer					
					Р	olymer L	oading (%)				
Monomer (%)		А	M			В	MA			:	\mathbf{ST}	
in MeOH (v/v)	В	NV	TP	ТМ	В	NV	TP	ТМ	В	NV	TP	ТМ
10	10	15	22	20	7	11	26	39	5	8	12	15
20	12	20	28	47	12	26	32	189	11	21	26	56
30	51	80	93	183	34	41	78	196	20	32	39	80
50	68	89	128	202	50	52	83	228	27	35	43	130
60	86	115	159	192	55	62	108	223	30	39	51	128
70	102	133	163	187	63	71	145	222	35	48	62	125
80	82	90	105	145	90	92	160	172	38	46	67	123
90	74	79	91	123	96	108	164	160	41	43	70	123
						Olig	omer					
					Р	olymer L	oading (%)				
Monomer (%)		А	M			В	MA			5	ST	
in MeOH (v/v)	В	UA	EA	PEA	в	UA	EA	PEA	в	UA	EA	PEA
10	10	14	35	40	7	24	43	53	5	6	11	13
20	12	19	48	68	12	28	52	103	11	18	27	28
30	51	66	102	152	34	32	89	143	20	23	36	41
50	68	83	142	184	50	73	83	276	20	20 31	45	55
60	86	104	166	248	55	86	103	281	30	36	52	63
70	102	143	196	279	63	92	156	284	35	42	59	73
80	82	101	160	101	90	106	204	192	38	48	72	96
90	74	96	132	123	96	112	201	196	41	51	88	103

Table I Polymer Loadings (PL) in Presence of Additives at Different Monomer/Methanol Compositions

B, Blank (monomer + MeOH); NV, = N-vinyl pyrrolidone (NVP), 1% v/v; TP, tripropylene glycol diacrylate (TPGDA), 1% v/v; TM, trimethylol propane triacrylate (TMPTA); 1% v/v.

All used by 1% w/v: UA, urethane acrylate; EA, epoxy acrylate; PEA, polyester acrylate.

exhibited the maximum PL values in the presence of AM, the minimum being with ST. The enhanced PL imparted by TMPTA is due to the branching effect of the TMPTA molecule. The trifunctional moiety is more prone to augmentation between substrate backbone polymer (cellulose) and the bulk monomer through its ability for favorable crosslinking process. Thus, the difunctional monomer (TPGDA) has the less potentiality than TMPTA for the crosslinking process between the substrate and the bulk monomer. This may explain the fact that the additive initially combines with the bulk monomer through the free radical mechanism, creating a secondary free radical to the bulk monomer, which, in turn, reacts with the substrate.⁵ Thus, the polymer loading, which is a measure of the extent of copolymerization, becomes higher as the functionality of the additives (and/or the bulk monomers) increases. However, when the mechanical strengths of the composites are considered, it is observed (Table II) that the composites formed in the presence of NVP are more mechanically strong than those formed with TPGDA and TMPTA. It was explained earlier³ that N-containing compound has the ability for better augmentation of the impregnating solution with the substrate backbone polymer (cellulose), though the polymer loading is found relatively low. The lone pair of electrons of the nitrogen may play some role for such behavior. Though TMPTA produces the highest PL values, it has yielded the composites with the second highest TS values in the series.

	A	M	BI	MA	ST		
Additives	\mathbf{PL}	T_{f}	\mathbf{PL}	T_f	\mathbf{PL}	T_f	
Blank	102	1.51	96	1.10	41	1.07	
NVP	133	1.75	108	1.83	48	1.31	
TPGDA	163	1.36	164	1.21	70	1.15	
TMPTA	202	1.52	228	1.56	131	1.26	
UA	143	1.65	112	1.60	51	1.31	
EA	196	1.18	204	1.21	88	1.12	
PEA	2 79	1.26	292	1.42	103	1.15	

Table IIEffect of Additives on TS of WPCof the Highest PL

TS, tensile strength; $T_f = TS_{wpc}/TS_{wood}$.

It is quite interesting that the additive PEA has produced the highest polymer loading in the series of oligomers (UA, EA, and PEA) used as additives. BMA + PEA system yields the maximum PL while ST + PEA system gives the minimum PL values. The AM + PEA system enhances PL values very close to that of the BMA system. AM + oligomersproduces the highest PL at 70% AM composition whereas the highest PL values obtained in ST + oligomers are at 90% ST concentration; but in the case of BMA + oligomers, these values are obtained at 80% BMA with the exception of UA + BMA, which yielded the highest PL at 90%. Among the series, UA yields the minimum PL values with the three bulk monomers. The maximum PL values rendered by PEA may be explained by the fact that polyester acrylate has a long chain backbone which can easily crosslink to form polymer. But epoxy acrylate (EA) has the epoxy groups along the oligomer backbone, which may delay the crosslinking process due to its structural or geometrical shape compared to that of the polyester. Urethane acrylate oligomer produces the minimum polymerization among the series, but the tensile strengths of the WPC formed in presence of UA as the additives are the highest. UA is an N-containing material like NVP. The presence of both these additives (UA and NVP) has been conducive to prepare WPC with enhanced TS. Apart from UA, PEA is more capable of producing WPC with stronger tensile property than EA. This is probably due to the better crosslinking ability of the PEA molecule with the bulk monomer and the substrate polymer backbones. Considering all the factors of PL and TS values, the BMA + simul system seems to be the best.

Effect of Coadditives

Sulfuric acid (H^+) , lithium nitrate (Li^+) , urea (U), and copper sulfate (Cu^{2+}) were used as coadditives

with the additives of multifunctional monomers (NVP, TPGDA, and TMPTA) and oligomers (UA, EA, and PEA) in order to study their effects on the polymer loading and tensile property of the WPC.

Acid (H⁺)

When sulfuric acid is used as the additive, polymer loading values enhance quite substantially; the order of the increment with the bulk monomers is AM > BMA > ST (Table III). Though the PL increases in the presence of H^+ ions, the tensile strengths (TS) decrease (Table IV) below the values of the tensile strength of the untreated wood. H⁺ ions break the long chain of the backbone polymer² (cellulose) of the substrate; thus, it renders reduced strength to the composites, even though it helps speed up the copolymerization process through the crosslinking of the individually segmented units of the polymer. When acid is used in combination with any additive selected from the monomer or oligomer series, it is observed that the PL values increase almost synergistically with all the additives except PEA, where PL values are suppressed in presence of H⁺ ions. The overall highest PL values are obtained with the BMA (bulk monomer) and TMPTA (additive) systems. Acidification of the impregnating solutions change the mobility of the solution at the equilibrium condition of the components during the copolymerization process at the zone of the reactivity associated with the partitioning of the various components present in the solutions. The rate of reactivity coupled with the partitioning is, thus, enhanced for the overall copolymerization process in the presence of the acid. However, PEA which has a long chain has the delaying effect during the partitioning compared to other molecules of the additives. Thus, the PL values with PEA are reduced in the presence of the acid.

Lithium Nitrate (Li⁺)

Incorporation of the lithium nitrate salt (1% w/v)into the formulations causes enhancement of the polymer loading with increased TS values for BMA and ST systems (Tables V, VI). There is, however, a slight reduction of TS values for the AM system when Li⁺ ions is added to AM + simul. The Li⁺ ion has favored the polymerization process, but this is not to the same extent as that due to H⁺ ion addition. The beauty of Li⁺ ion is that it does not break, like H⁺ ions, the long chain of the backbone polymer (cellulose) during the reactivity. It, rather, retains the tensile property of WPC. Li⁺ ion, thus, plays some significant part during the partitioning process in the overall WPC formation. Addition of Li⁺ ion

						Mono	omer					
					Po	lymer Lo	oading (%	5)				
Monomer (%) in MeOH		AM				BMA			ST			
(v/v)	H^+	а	b	c	H^{+}	а	b	с	H^{+}	а	b	с
10	13	60	63	86	33	52	59	192	6	13	16	53
20	20	81	70	98	43	80	70	240	18	30	25	96
30	70	145	113	187	56	123	83	269	26	45	46	116
50	91	129	188	238	89	203	163	269	42	63	68	163
60	116	218	196	234	92	210	169	270	52	80	82	155
70	151	230	216	225	94	216	173	278	65	115	99	145
80	105	180	171	196	106	220	179	290	72	110	100	143
90	93	152	123	152	118	225	181	282	74	114	109	140
						Oligo	omer					
					Po	olymer L	oading (%	6)				
Monomer (%)		А	М			B	MA			8	ST	
in MeOH (v/v)	\mathbf{H}^{+}	d	e	f	\mathbf{H}^{+}	d	е	f	\mathbf{H}^+	d	е	f
10	13	19	42	40	33	39	41	48	6	10	12	10
20	20	76	68	61	43	43	62	89	18	28	33	23
30	70	101	122	138	65	53	78	137	26	42	46	40
50	91	140	167	153	89	86	103	210	42	62	59	51
60	116	175	192	214	92	92	105	222	52	65	69	60
70	151	189	204	252	94	111	108	202	65	73	73	68
80	105	145	183	151	106	108	121	142	72	82	88	79
90	93	143	153	112	118	102	131	116	74	84	90	89

 Table III Effect of Coadditive Acid (H⁺) on PL in Presence of Additives

 at Different Monomer/Methanol Compositions

a, NVP + H⁺; b, TPGDA + H⁺; c, TMPTA + H⁺; d, UA + H⁺; e, EA + H⁺; f, PEA + H⁺; H⁺, H₂SO₄; 1% v/v.

as coadditive to the formulations containing bulk monomer and an additive (the latter being taken from monomer or oligomer series) causes substantial

Table IV	Effect of Acid (H ⁺) on TS of WPC with	
the Highes	st PL	

	Α	M	BI	MA	ST		
Additives and H ⁺	PL	T_f	PL	T_f	PL	T_f	
H+	151	0.80	118	0.70	74	0.72	
$NVP + H^+$	230	1.22	225	1.09	114	1.12	
$TPGDA + H^+$	216	0.68	181	0.65	109	0.75	
$TMPTA + H^+$	238	0.82	290	0.88	163	0.92	
$UA + H^+$	189	0.87	111	0.68	84	0.72	
$EA + H^+$	204	1.11	131	1.01	90	1.01	
$PEA + H^+$	252	1.03	222	1.02	89	0.98	

enhancement of PL values with almost all the series of AM, BMA, and ST except for the oligomer additives with AM and BMA where there has been some depletion of the PL values when Li^+ ion is added to AM + oligomers and BMA + oligomers. With some exceptions, in most of the cases, TS values have increased with the enhanced PL. This is an added merit of Li^+ ions being used as coadditives in place of H^+ ions.

Urea (U)

When urea is added to the bulk monomer, the PL increases with enhanced TS values with all three systems of AM, BMA, and ST (Tables VII, VIII). This increment in PL values is higher than Li^+ ion systems but lower than H^+ ion systems. The enhanced TS values in the presence of urea is very

						Mono	mer						
					Po	lymer Lo	ading (%)					
Monomer (%) in MeOH	AM					BMA				ST			
(v/v)	Li^+	а	b	с	Li^+	а	b	с	Li ⁺	a	b	c	
10	10	16	19	25	14	10	27	42	4	8	11	17	
20	18	19	33	53	30	28	33	202	12	23	28	62	
30	62	83	107	195	47	45	76	220	23	38	35	92	
50	86	96	142	231	82	58	90	240	35	45	52	152	
60	101	126	176	208	86	71	118	235	43	53	63	148	
70	136	153	183	198	88	89	163	231	52	58	78	142	
80	98	97	126	156	97	109	165	183	57	93	83	140	
90	83	83	102	133	103	121	169	163	59	88	97	131	
						Oligo	mer						
					Ро	lymer Lo	ading (%)					
Monomer (%) in MeOH		А	М			BI	ИA			s	Т		
(v/v)	Li^+	d	е	f	Li ⁺	d	е	f	Li^+	d	e	f	
10	10	13	18	28	14	10	16	26	4	7	13	12	
20	18	35	40	51	30	28	32	35	12	24	28	31	
30	62	70	90	109	47	71	61	66	23	28	42	42	
50	86	98	118	126	82	82	83	93	35	39	51	65	
60	101	114	129	143	86	93	96	115	43	40	63	86	
70	136	128	142	162	88	109	103	129	52	42	79	98	
80	98	121	136	143	97	120	121	138	57	68	87	106	
90	83	102	116	120	103	118	131	146	59	78	99	123	

 Table V
 Effect of Coadditive Lithium (Li⁺) on PL in Presence of Additives

 at Different Monomer/Methanol Compositions

a, NVP + Li^+ ; b, TPGDA + Li^+ ; c, TMPTA + Li^+ ; d, UA + Li^+ ; e, EA + Li^+ ; f, PEA + Li^+ ; Li^+ , $LiNO_3$; 1% w/v.

significant. Thus, when H^+ ions, Li^+ , and urea are considered as the additives incorporated to any of the three bulk monomers, it is observed (Tables II,

Table VI Effect of Lithium (Li⁺) on TS of WPC with the Highest PL

A .1 11/1	A	M	BI	MA	ST		
Additives and Li ⁺	\mathbf{PL}	T_f	PL	T_{f}	\mathbf{PL}	T_f	
Li ⁺	136	1.32	103	1.26	59	1.16	
$NVP + Li^+$	153	1.59	121	1.46	93	1.58	
$TPGDA + Li^+$	183	1.41	169	1.36	97	1.32	
$TMPTA + Li^+$	231	1.63	240	1.66	152	1.62	
$UA + Li^+$	128	1.26	120	1.21	78	1.19	
$EA + Li^+$	142	1.28	131	1.19	89	1.21	
$PEA + Li^+$	162	1.23	146	1.18	123	1.29	

V, and VII) that urea is the best additive to be chosen for such purposes, because WPC formed in the presence of urea (1% w/v) yields high PL along with enhanced TS values. Urea is also cheap compared to Li-salt and acid. Electron density around the two carbonyl groups (=C=0) as well as beside the N-atom of the urea molecule may play some important role for diffusion/partitioning of the required component during the copolymerization process at the equilibrium condition phenomena of the system. Use of urea in combination with monomers (NVP, TPGDA, and TMPTA) and oligomers (UA, EA, and PEA) yields WPC, which exhibits sufficiently enhanced PL values with significant increment of TS. The highest TS values attained in the presence of NVP is of much interest. The effect of bulk monomers (AM, BMA, and ST) on PL and TS values in the presence of urea combined with an additive

						Monor	ner					
					Pol	ymer Loa	ading (%)					
Monomer (%) in MeOH	AM				BMA			ST				
(v/v)	U	а	b	с	U	а	b	с	U	a	b	с
10	12	27	24	22	11	23	29	53	6	11	18	22
20	16	96	43	66	33	68	43	209	18	30	35	83
30	67	183	153	167	48	82	99	246	25	55	53	113
50	82	242	202	192	73	101	172	230	35	68	62	156
60	109	212	268	143	81	123	199	222	42	81	82	152
70	143	156	216	96	92	143	204	220	49	92	96	143
80	99	121	148	82	109	176	236	221	56	90	00	140
90	81	87	119	43	138	222	241	216	62	86	103	141
						Oligo	mer					
					Pol	lymer Lo	ading (%))				
Monomer (%) in MeOH		А	М			В	MA				ST	
(v/v)	U	d	е	f	U	d	е	f	U	d	е	f
10	12	16	24	22	11	42	46	51	6	8	12	12
20	16	38	58	52	33	51	76	102	18	16	28	26
30	67	75	99	96	48	64	93	153	25	29	41	39
50	82	102	133	137	73	95	119	296	35	40	53	56
60	109	135	142	148	81	97	178	298	42	46	58	66
70	143	151	163	160	92	103	229	303	49	53	66	78
80	99	120	156	152	109	116	221	210	56	62	91	81
90	81	105	149	135	138	122	205	213	62	67	97	82

Table VIIEffect of Coadditive U on PL in Presence of Additivesat Different Monomer/Methanol Compositions

a, NVP + U; b, TPGDA + U; c, TMPTA + U; d, UA + U; e, EA + U; f, PEA + U; U, Urea, 1% w/v.

(monomer or oligomer) is reflected in these results in the sense that the highest PL and TS values are obtained with AM + NVP + U in the series of AM

Table VIII	Effect of	Urea (U)	on T	S of WPC
with the Hig	ghest PL			

	A	M	BI	MA	ST		
Additives and U	PL	T_f	PL	T_f	PL	T_{f}	
U	143	1.43	138	1.36	62	1.12	
NVP + U	243	1.90	222	1.85	92	1.78	
TPGDA + U	268	1.55	241	1.45	103	1.47	
TMPTA + U	192	1.63	246	1.71	156	1.76	
UA + U	151	1.70	122	1.69	67	1.25	
EA + U	163	1.23	229	1.24	97	1.32	
PEA + U	160	1.12	303	1.35	82	1.48	

+ monomer additives, whereas TMPTA + U shows the maximum PL values in BMA and ST systems in the presence of urea.

Copper Sulfate (Cu²⁺ Ions)

Cupric ion (Cu^{2+}) is known to play some significant role in the radiation process of the liquid solution, particularly through the electron-transfer mechanism⁶ from the primary free radicals to Cu^{2+} ions. Results in the Table IX show that there has been some depletion of the polymer loading in the presence of Cu^{2+} ions with the bulk monomers. This effect of Cu^{2+} ions is relatively low with ST compared to BMA and AM. It is of interest to note that the composites formed in the presence of Cu^{2+} ions retain their TS values without any reduction, though the PL values have been reduced, to some extent,

						Mono	mer						
	Polymer Loading (%)												
Monomer (%) in MeOH	AM					BMA				ST			
(v/v)	Cu ²⁺	а	b	с	Cu ²⁺	a	b	c	Cu ²⁺	а	b	c	
10	0	0	2	8	0	0	8	20	0	0	0	2	
20	8	9	7	36	9	12	17	162	7	9	12	40	
30	48	75	83	178	19	29	60	178	16	21	27	71	
50	62	83	111	196	41	37	75	159	19	29	33	119	
60	84	105	143	189	48	53	98	157	23	32	43	120	
70	98	128	152	182	53	81	103	144	28	37	49	108	
80	82	86	97	141	87	87	131	133	32	36	56	103	
90	71	79	82	119	90	106	132	129	35	34	62	104	
						Oligo	mer						
					Pol	ymer Lo	ading (%)					
Monomer (%) in MeOH		A	м			Bl	MA			S	Т		
(v/v)	Cu^{2^+}	d	е	f	Cu^{2+}	d	e	f	Cu^{2+}	d	e	f	
10	0	3	12	22	0	12	27	34	0	0	0	1	
20	8	8	29	48	9	28	43	62	7	9	11	42	
30	48	51	83	143	19	29	93	123	16	17	38	34	
50	62	78	136	168	41	66	97	178	19	26	41	49	
60	84	97	152	238	48	78	123	267	23	32	48	55	
70	98	136	185	268	53	83	179	283	28	38	52	68	
80	82	92	151	147	87	98	181	289	32	41	72	83	
90	71	82	122	106	90	101	196	293	35	45	82	97	

Table IX Effect of Coadditive Copper (Cu²⁺) on PL in Presence of Additives at Different Monomer/ Methanol Compositions

a, NVP + Cu²⁺; b, TPGDA + Cu²⁺; c, TMPTA + Cu²⁺; d, UA + Cu²⁺; e, EA + Cu²⁺; f, PEA + Cu²⁺; Cu²⁺, CuSO₄, 1% w/v.

from those of simul + bulk monomer systems. Similar behavior of Cu²⁺ was also observed with the ST + simul system in the presence of these additives.⁷ This is possibly due to favorable Cu²⁺ ionic mobility of the organometallic complex formed at the equilibrium condition of the cellulose backbone of the substrate. This helps better augmentation of the organometallic moiety with the substrate (simul) cellulose backbone for preparing WPC. Copper is also known to be used for preservation and protection purposes. Thus, WPC formed with Cu²⁺ ions retains tensile strength with very little reduction of PL and can act for preservative and protective purposes of the composites. Combination of Cu²⁺ ions with polyfunctional monomers (NVP, TPGDA, and TMPTA) or with oligomers (UA, EA, and PEA)

used as additives increases polymer loadings of the bulk monomer in the order AM > BMA > ST in the case of the polyfunctional monomer series. This increment is in favor of the functionality of the additive monomer. This means TMPTA shows the highest PL values among NVP and TPGDA. The above order of bulk monomers changes to BMA > AM > ST when oligomers are used as the additives. PEA systems show the maximum PL values. The impact of oligomer is more dominant in the presence of Cu^{2+} ions than the polyfunctional monomers. This shows that oligomers have a more favorable partitioning/diffusion mechanism in the presence of Cu^{2+} ions than the polyfunctional monomers. It is observed in Table X that the tensile strength of the composites containing Cu^{2+} ions are

	A	М	BN	MА	ST		
Additives and Cu ²⁺	PL	T_f	PL	T_{f}	PL	T_{f}	
Cu ²⁺	98	1 <i>.</i> 53	90	1.11	35	1.06	
$NVP + Cu^{2+}$	128	1.72	106	1.80	37	1.34	
$TPGDA + Cu^{2+}$	152	1.32	132	1.20	62	1.12	
$TMPTA + Cu^{2+}$	196	1.53	178	1.55	119	1.22	
$UA + Cu^{2+}$	136	1.28	101	1.63	45	1.28	
$EA + Cu^{2+}$	185	1.21	196	1.26	82	1.12	
$PEA + Cu^{2+}$	268	1.23	293	1.40	97	1.14	

Table XEffect of Copper (Cu2+) on TS of WPCwith the Highest PL

more or less similar to those (Table II) of the composites without Cu^{2+} ions. Thus, when additives (NVP, TPGDA, and TMPTA) are used to the bulk monomer (AM, BMA, and ST) and then Cu^{2+} ions are incorporated into it, the overall PL and TS values are almost the same as those of the composites without the Cu^{2+} ions; but these composites can be used as preservative and protective materials due to the presence of Cu^{2+} ions in it. The composites can be used for the preservation of arts and antiques.

Mixed Coadditives

It is now understood that sulfuric acid $(H^+ \text{ ions})$ used as coadditive in the simul + bulk monomers + additives systems increases polymer loading almost synergistically with a drastic reduction of the tensile properties of the composites. On the other hand, both Cu²⁺ and Li⁺ ions play moderate roles as the coadditives in place of H^+ ions. Li^+ ions slightly enhance the polymer loadings and tensile strengths, whereas Cu²⁺ ions retain both PL and TS values almost at the same levels as if no Cu²⁺ ion was used. But WPC formed with Cu²⁺ ions can be used for protective and preservative purposes. Urea plays the best role in the WPC formation. It increases both PL and TS quite significantly. It is worth investigating the impact of mixed coadditives on WPC formation. Since Cu²⁺ ions do not alter PL and TS values of the composites very much, it is desirable that Cu^{2+} ion can be mixed with H^+ ions or Li⁺ ions or urea in order to study the impact of the mixed coadditives in the WPC formation.

$Cu^{2+} + H^+$ lons

Table XI shows the polymer loading of the composites formed in presence of $Cu^{2+} + H^+$ ions, and bulk monomers and/or additives (monomers or oligomers). When these results are compared with those of Tables I-IX, it is observed that PL values are slightly enhanced in presence of $Cu^{2+} + H^+$ ions, particularly with polyfunctional monomers. In fact, these values of PL are reduced when oligomer additives are used (Table XI). The enhancement due to $Cu^{2+} + H^+$ ions is not to the same extent as that due to H⁺ ions alone (Table III). Thus, it shows that Cu²⁺ ions have suppressed the copolymerization process which could have occurred in the presence of H^+ ions. One possibility is that some H^+ ions reacted with Cu²⁺ ions in the related organometallic compound and/or some other entities. It is known that involvement of Cu²⁺ ions alone in the WPC formation does not reduce PL and TS values whereas incorporation of H⁺ ions into any system reduces the TS values with enhanced PL values. But the TS results given in Table XII show that the composites formed with AM monomer in the presence of $Cu^{2+} + H^+$ ions and polyfunctional monomers (additives) have less tensile strength, indicating involvement of H⁺ ions as more dominating than Cu²⁺ ions in the WPC formation. This behavior changes as the bulk monomer is replaced by another bulk monomer. For example, WPC with ST yields TS values which are greater than those of the system containing H⁺ ions (Table IV) but are very slightly smaller than those with Cu²⁺ ions. This shows that molecular structure of the bulk monomer plays a significant role during the partitioning/diffusion of the molecules at its equilibrium condition.⁴ This is further complicated by the process of ionic involvements. Thus, Cu²⁺ and H⁺ ions play their respective roles during the equilibrium condition of the bulk monomer and other related components.

$Cu^{2+} + Li^+$ lons

The behavior of $Cu^{2+} + Li^+$ ions is different from other systems. It is already observed in Table V that Li⁺ ions have enhanced the PL values, particularly in the presence of the polyfunctional monomers (additives) and slightly reduced PL values when oligomers are used as additives. But this enhancement of PL is slightly suppressed when Cu^{2+} ions are incorporated with Li⁺ ions (Table XIII). This is true in both the systems of the additives (monomers and oligomers). Cu^{2+} ions have the tendency to suppress PL values when used alone with retention of the TS property. The overall enhancement of the tensile strengths of the composites in the presence of $Cu^{2+} + Li^+$ ions (Table XIV) indicate that both Cu²⁺ and Li⁺ ions have played some important roles in the composite formation. It seems

					М	onome	r					
					Polyme	r Loadi	ng (%)					
Monomer (%) in MeOH		AM				BMA				ST		
(v/v)	$Cu^{2+} + H^+$	Α	В	С	$Cu^{2+} + H^+$	Α	В	С	$Cu^{2+} + H^+$	A	в	С
10	6	52	51	65	18	41	34	267	2	8	7	18
20	11	72	60	77	29	82	54	267	11	25	34	78
30	58	123	97	156	51	111	75	268	21	37	46	98
50	83	105	158	211	83	183	159	275	35	55	59	143
60	95	186	172	202	82	185	163	255	46	84	63	136
70	113	201	195	200	89	196	163	261	61	105	88	133
80	92	161	148	187	95	203	168	269	63	105	90	134
90	81	129	103	133	112	207	169	268	70	108	92	121
					O	igome	r					
					Polyme	r Loadi	ng (%)					
Monomer (%) in MeOH		AM				BMA				ST		
(v/v)	$\mathrm{Cu}^{2+} + \mathrm{H}^+$	D	Ε	\mathbf{F}	$Cu^{2+} + H^+$	D	Ε	\mathbf{F}	$\mathrm{Cu}^{2+} + \mathrm{H}^+$	D	Ε	F
10	6	8	28	24	18	33	35	42	2	3	5	6
20	11	63	52	46	29	38	54	87	11	15	17	18
30	58	89	96	112	51	47	72	125	21	35	36	33
50	83	123	146	123	83	77	97	201	35	56	43	46
60	95	158	178	189	82	88	100	211	46	60	52	50
70	113	166	190	234	89	98	107	216	61	66	68	57
80	92	122	172	130	95	96	117	122	63	71	73	66
90	81	123	138	87	112	92	123	136	70	79	76	72

Table XI Effect of Coadditives Copper (Cu^{2+}) and Acid (H^+) on PL in Presence of Additives at Different Monomer/Methanol Compositions

A, NVP + Cu^{2+} + H⁺; B, TPGDA + Cu^{2+} + H⁺; C, TMPTA + Cu^{2+} + H⁺; D, UA + Cu^{2+} + H⁺; E, EA + Cu^{2+} + H⁺; F, PEA + Cu^{2+} + H⁺. All additives and coadditives were used by 1% v/v or w/v.

Table XII	Effect of Copper	: (Cu ²⁺) and	Acid (H ⁺) on	TS of WPC	with the Highest PL
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	A	M	Bl	MA	ST		
Additives and Cu ²⁺ + H ⁺	PL	T_{f}	PL	T_{f}	PL	T_f	
$Cu^{2+} + H^+$	113	0.89	112	0.74	70	0.96	
$NVP + Cu^{2+} + H^+$	201	1.16	207	1.11	108	1.23	
$TPGDA + Cu^{2+} + H^+$	195	0.76	169	0.65	92	0.94	
$TMPTA + Cu^{2+} + H^+$	211	0.88	275	0.90	143	1.14	
$UA + Cu^{2+} + H^+$	166	0.87	98	0.63	79	1.08	
$EA + Cu^{2+} + H^+$	190	1.02	123	0.98	76	1.10	
$PEA + Cu^{2+} + H^+$	234	1.06	211	1.00	72	1.06	

					Mo	nomer	•					
	Polymer Loading (%)											
Monomer (%)		AM				BMA				ST		
in MeOH (v/v)	$Cu^{2+} + Li^+$	A	В	С	$Cu^{2+} + Li^+$	А	В	С	$Cu^{2+} + Li^+$	Α	в	С
10	8	8	9	15	6	6	14	34	0	7	8	12
20	10	12	21	37	21	12	24	167	8	17	19	48
30	56	63	96	176	33	34	55	188	20	33	30	86
50	80	85	128	211	73	44	69	192	29	42	47	143
60	97	112	154	196	74	58	93	185	36	44	52	136
70	129	140	175	188	72	68	146	186	48	51	67	136
80	87	82	108	137	85	90	146	159	51	84	71	132
90	78	69	83	122	93	107	139	145	42	82	88	127
					Ol	igomer						
					Polymer	Loadir	ng (%)					
Monomer (%)		AM				BMA				ST		
in MeOH (v/v)	$Cu^{2+} + Li^+$	D	Ē	F	$Cu^{2+} + Li^+$	D	Ε	F	$Cu^{2+} + Li^+$	D	Ε	F
10	8	9	11	14	6	5	10	16	0	3	8	10
20	10	22	28	38	21	18	23	26	8	16	18	24
30	56	60	81	96	33	62	52	55	20	23	38	33
50	80	86	107	111	73	74	68	82	29	33	47	62
60	97	102	113	125	74	85	83	103	36	36	52	75
70	129	110	125	147	72	98	96	115	48	38	66	91
80	87	109	118	130	85	105	112	129	51	60	71	87
90	78	89	103	112	93	106	119	133	42	72	92	92

Table XIII Effect of Coadditives Copper (Cu²⁺) and Lithium (Li⁺) on PL in Presence of Additives at Different Monomer/Methanol Compositions

A, NVP + $Cu^{2+} + Li^+$; B, TPGDA + $Cu^{2+} + Li^+$; C, TMPTA + $Cu^{2+} + Li^+$; D, UA + $Cu^{2+} + Li^+$; E, EA + $Cu^{2+} + Li^+$; F, PEA + $Cu^{2+} + Li^+$.

Table XIV	Effect of Copper (Cu	1 ²⁺) and Lithium (Li ⁺) on '	TS of WPC with the Highest PL
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A 1 11 1 1	A	M	BI	MA	ST		
$\begin{array}{c} \text{Additives and} \\ \text{Cu}^{2+} + \text{Li}^+ \end{array}$	PL	T_{f}	PL	T_{f}	PL	T_{f}	
$Cu^{2+} + Li^+$	129	1.39	93	1.25	48	1.13	
$NVP + Cu^{2+} + Li^+$	140	1.56	107	1.43	82	1.69	
$TPGDA + Cu^{2+} + Li^+$	175	1.46	146	1.32	88	1.34	
$TMPTA + Cu^{2+} + Li^+$	211	1.68	192	1.60	143	1.65	
$UA + Cu^{2+} + Li^+$	110	1.27	106	1.26	72	1.16	
$\mathbf{EA} + \mathbf{Cu}^{2+} + \mathbf{Li}^+$	125	1.30	119	1.20	92	1.20	
$PEA + Cu^{2+} + Li^+$	147	1.22	133	1.18	110	1.31	

that both Cu^{2+} and Li^+ ions may have actively entered into the copolymerization process. But this needs more elaborate investigation for ascertaining its proper function at the equilibrium condition of the different components of the impregnating solution. It is already known that Li^+ ion is a good replacement of H⁺ ions and Cu^{2+} ion is also known to act as protective and preservative purposes of the composite material. Thus, the combination of Cu^{2+} and Li^+ ions may be of good application in the composite formation when factors like preservation and strong tensile strength of the WPC are considered.

$Cu^{2+} lons + U$

80

90

81

78

The high polymerizing capacity of urea for the bulk monomers in the presence of both the series of additives (except AM + oligomers) is very slightly suppressed by the incorporation of Cu^{2+} ions with urea (Tables VII and XV). Tensile strengths (Table XVI) of the WPC are also high. That is the effect of Cu^{2+} ions not possibly reflected on the tensile property. Among the three sets of mixed coadditives $(Cu^{2+} + H^+, Cu^{2+} + Li^+, and Cu^{2+} + U), Cu^{2+} + U$ set seems to be the best so far considering polymer loading and tensile strength. Whatever may be the case, it is obvious that the combination of coadditives to the additives makes the copolymerizing process more complex. This is further complicated when the effect of radiation itself is taken into account.

Copolymerization of the bulk monomers (AM, BMA, and ST) reveals that styrene plays some hinderic effect due to the fact that aromatic ring stays

Table XV Effect of Coadditives Copper (Cu^{2+}) and Urea (U) on PL in Presence of Additives at Different Monomer/Methanol Compositions

					М	lonome	r						
		Polymer Loading (%)											
Monomer (%)		AM				BMA				ST			
in MeOH (v/v)	$Cu^{2+} + U$	Α	В	С	$Cu^{2+} + U$	Α	В	С	$Cu^{2+} + U$	A	В	С	
10	8	19	16	19	10	21	22	43	0	7	10	12	
20	9	91	33	59	21	42	36	193	12	23	29	78	
30	52	178	142	253	40	71	87	230	22	51	43	109	
50	76	236	196	283	63	103	163	216	29	62	59	141	
60	99	208	252	236	76	153	183	211	35	74	73	140	
70	133	143	101	182	88	193	198	215	42	91	92	136	
80	81	117	132	179	98	196	230	209	52	86	96	136	
90	78	81	106	133	122	196	235	208	56	86	98	122	
					0	ligome	r						
					Polyme	r Loadi	ng (%)						
Monomer (%)		AM				BMA	L			ST			
in MeOH (v/v)	$Cu^{2+} + U$	D	\mathbf{E}	F	$Cu^{2+} + U$	D	Е	F	$Cu^{2+} + U$	D	Е	F	
10	8	11	13	18	10	31	36	43	0	7	9	9	
20	9	32	43	46	21	45	71	92	12	14	19	22	
30	52	70	82	88	40	56	83	135	22	28	34	36	
50	76	93	121	129	63	85	99	270	29	36	45	52	
60	99	129	130	140	76	88	162	281	35	43	51	63	
70	133	147	156	151	88	92	218	287	42	50	62	77	

A, NVP + Cu^{2+} + U; B, TPGDA + Cu^{2+} + U; C, TMPTA + Cu^{2+} + U; D, UA + Cu^{2+} + U; E, EA + Cu^{2+} + U; F, PEA + Cu^{2+} + U.

98

122

201

197

111

113

193

278

52

56

58

63

80

82

73

72

143

138

142

129

115

96

A 13% 1	A	M	BI	MA	ST		
Additives and Cu ²⁺ + U	PL	T_{f}	PL	T_{f}	PL	T_{f}	
$Cu^{2+} + U$	133	1.44	122	1.35	56	1.20	
$NVP + Cu^{2+} + U$	236	1.92	196	1.80	91	1.78	
$TPGDA + Cu^{2+} + U$	252	1.58	225	1.46	98	1.46	
$TMPTA + Cu^{2+} + U$	283	1.66	230	1.70	141	1.72	
$UA + Cu^{2+} + U$	147	1.71	113	1.65	63	1.26	
$\mathbf{EA} + \mathbf{Cu}^{2+} + \mathbf{U}$	156	1.25	218	1.28	82	1.30	
$\mathbf{PEA} + \mathbf{Cu}^{2+} + \mathbf{U}$	151	1.10	287	1.33	77	1.44	

Table XVI Effect of Copper (Cu²⁺) and Urea (U) on TS of WPC with the Highest PL

outside the vinyl plane, and, thus, the partitioning/ diffusion of the styrene molecule is relatively slow than AM and BMA molecules. This is one of the reasons which yields low polymer loading with styrene. Acrylamide (AM), on the other hand, has the impact due to — CONH₂ group and BMA has the long chain backbone effect on the copolymerization process. These effects are well demonstrated in their results. H⁺ ions increase the polymer loading synergistically but reduce tensile strength substantially. Li⁺ ions maintain the enhanced polymer loading with moderate change of tensile property whereas Cu²⁺ ions reduce PL slightly with little effect on TS values.

Use of inorganic salts $(Cu^{2+} \text{ and } Li^+)$ and urea is important in the sense that this is a new area for preparing composites (WPC) of different valuable properties like color, preservation, protection, etc. The composites formed in the presence of such additives and coadditives may serve some specific purposes. The authors acknowledge the International Atomic Energy Agency (IAEA) for granting them financial support under the Technical Assistance Program BGD/8/008.

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